INSPECTION CERTIFICATE

495E25S

TAIYO INK MFG. CO., LTD.

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General Judgment

PASS

Nov. 15.2019

FLEXFINER-25SA

Lot No. 9111317

Items	Test method	Specifications	Result
Appearance	Visual inspection (□100mm)	No difference in hue between lot. No uneven coating, stripe, roll-up wrinkle and pin-hole.	PASS
Resist thickness	Stylus profile measuring system	A-layer:5.0+/-1.0 μ m A+B layers:25.0+/-2.0 μ m	5.5 μ m 24.4 μ m
Film width	JIS 1(st) class grade (Just after the Slit)	495.0+/-1.0mm	495mm
Photo sensitivity (Provisional)	On FR-4 base material Step tablet:Kodak No. 2 at 2:0mJ/cm2 on the cover-film PEB(preheat)condition after exposure: 90°C/40min.	Gloss photo sensitivity 3 MIN. Residual photo sensitivity 7 MIN.	Na. 4
Developability	100℃/25min. after Lamination lwt% Na2CO3 30℃ 0.196MPa (2kg/c㎡) 60sec	No ink residue remains No blister and/or No peeling of solder resist after development	PASS

Remarks:

Exposure(Contact Exposure)

High-pressure mercury short arc lamp at 210mJ/cm2 on the cover-film

PEB (preheat)

Hot-air convection oven 90℃/40min.

Post cure

Hot-mir convection oven150℃ for 60min.

Pencil hardness	TAIYO Internal Test Method (GIP-011A)	3H or above	3Н
Adhesion	TAIYO Internal Test Method (GIP-012A)	100/100	100/100
	TAIYO Internal Test Nethod (GIP-013B)		
Solder resistance	Use rosin-bused flux at	No blister and/or No peeling	PASS
	10sec. × lcycle, 260 ± 5℃	of solder resist	
	Immersed in propylene glycol-monomethyl	No blister and/or No peeling	
Solvent resistance	ether acetate at 20℃ for 20min.	of solder resist	PASS

RoHS Compliance

Approved by:

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